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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/082,228	02/26/2002	Satoshi Tatsuura	106200.01	4600
7:	590 07/14/2004		EXAM	NER
Oliff & Berridge PLC			WONG, EDNA	
P.O. Box 19928 Alexandria, VA 22320			ART UNIT	PAPER NUMBER
*			1753	
			DATE MAILED: 07/14/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicanto			
			Applicant(s)			
Office Antique Comments		10/082,228	TATSUURA ET AL.			
	Office Action Summary	Examiner	Art Unit			
		Edna Wong	1753			
Period f	The MAILING DATE of this communication app or Reply	pears on the cover sheet with the c	orrespondence address			
THE - External control	MORTENED STATUTORY PERIOD FOR REPL' MAILING DATE OF THIS COMMUNICATION. ensions of time may be available under the provisions of 37 CFR 1.1 r SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a reply operiod for reply is specified above, the maximum statutory period of ure to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be tin y within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	nely filed s will be considered timely. I the mailing date of this communication. D (35 U.S.C. § 133).			
Status						
1)[Responsive to communication(s) filed on 25 Ju	une 2004.				
		action is non-final.				
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposit	ion of Claims					
5)□ 6)⊠ 7)□ 8)□	Claim(s) 30-37 is/are pending in the application 4a) Of the above claim(s) is/are withdraw Claim(s) is/are allowed. Claim(s) 30-37 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or claim(s) are subject.	wn from consideration.				
Applicat	ion Papers					
	9) The specification is objected to by the Examiner.					
10)	☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.					
	Applicant may not request that any objection to the	· · · · · ·	* *			
11)	Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Ex					
Priority (under 35 U.S.C. § 119					
a)	Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority document: 2. Certified copies of the priority document: 3. Copies of the certified copies of the priority document: application from the International Bureau See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	ion No. <u>09/571,864</u> . ed in this National Stage			
Attachmen	• •					
	ce of References Cited (PTO-892)	4) ☐ Interview Summary Paper No(s)/Mail Da				
3) 🔲 Infor	ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) er No(s)/Mail Date		atent Application (PTO-152)			

This is in response to the Amendment dated June 25, 2004. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Response to Arguments

Claim Rejections - 35 USC § 102

Claims **30-37** have been rejected under 35 U.S.C. 102(b) as being anticipated by **Melcher et al.** (US Patent No. 4,217,183).

The rejection of claims 30-37 under 35 U.S.C. 102(b) as being anticipated by Melcher et al. is as applied in the Office Action dated May 5, 2004 and incorporated herein. The rejection has been maintained for the following reasons:

Applicants state that Melcher does not teach an apparatus comprising a pulse laser. Instead, Melcher only discloses continuous lasers, such as argon lasers or krypton lasers, and makes a pulse beam by chopping that continuous laser beam mechanically. Thus, the apparatus of the present invention is clearly different than the apparatus described in Melcher.

In response, the "pulse laser" as presently claimed does not recite any specific structure. Thus, the "pulse laser" as presently claimed is opened to the pulse laser arrangement disclosed by Melcher which comprises a light source 22 and a modulator 28.

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THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edna Wong whose telephone number is (571) 272-1349. The examiner can normally be reached on Mon-Fri 7:30 am to 5:00 pm, alt. Fridays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (571) 272-1342. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Edna Wong Primary Examiner Art Unit 1753

EW July 10, 2004